

## DAFTAR PUSTAKA

- Azizahwati. (2002). *Studi Morfologi Permukaan Film Tipis Pb<sub>z</sub>R<sub>0,525</sub>Ti<sub>0,475</sub>O<sub>3</sub> yang Ditumbuhkan Dengan Metode DC UN-Balanced Magnetron Sputtering*. [Online] Tersedia : .
- Barnat, Edward V. & Lu, Toh-Ming. (2003). *Pulsed and Pulsed Bias Sputtering : Principles and Applications*. Massachusetts : Kluwer Academic Publishers.
- Elshabini – Riad, Aicha & Barlow, Fred D. (1998). *Thin Film Technology Handbook*. New York : Mcgraw – Hill.
- Fowler. (1946). *Introduction to Electric Theory*. Cambridge : Addison – Wesley.
- Latununuwe, Altje dkk. (2008). *Bipolar Penumbuhan Nano-katalis Co-Fe Dengan Metode Sputtering*. [Online] Tersedia : .
- Lew, Kristi. (2008). *Argon*. New York : The Rosen Publishing Company, Inc.
- Lubis, Patricia, Latununuwe, Altje & Winata, Toto. (2009). *Penumbuhan Nanopartikel Nikel dengan DC-Unbalanced Magnetron Sputtering*. [Online] Tersedia : .
- Morton, Dale E., Konopka, David & Zimone, Frank T. (1999). *Bipolar Pulsed DC Sputtering of Optical Films*. [Online] Tersedia : [www.fke.utm.my/elektrika/dec07/paper4dec07.pdf](http://www.fke.utm.my/elektrika/dec07/paper4dec07.pdf).
- Rusdiana, Dadi. (2005). *Pengaruh Temperatur Deposisi Lapisan Penyangga Aluminium Nitrida Terhadap Struktur Kristal dan Morfologi Film Tipis*

*GaN dengan Metode DC Unbalanced Magnetron Sputtering*. [Online]  
Tersedia : <http://jms.fpmipa.itb.ac.id>.

Samarasekara, P, dkk., (2005). *Photocurrent Enhancement of DC Sputtered Copper Oxide Thin Films*. [Online] Tersedia :

Samarasekara, P & Yapa, N.U.S. (2007). *Effect of Sputtering Conditions On The Gas Sensitivity of Copper Oxide Thin Films*. [Online] Tersedia :

Smith, D. Leonard. (1995). *Thin Films Deposition : Principles and Practice*. New York : Mcgraw Hill.

Soohee, Ronald F. (1965). *Magnetic Thin Films*. New York : Harper & Rows Publisher.

Sutrisno & Tan Ik Gie. (1979). *Fisika Dasar. Listrik, Magnet dan Termofisika*. Bandung : Penerbit ITB.

Thornton, J. A. (2000). *Deposition Technologies for Films and Coatings*. New Jersey : Noyes Publications.

Wasa, Kiyotaka, Kitabatake, Makoto, & Adaichi, Hideaki. (). *Thin Film Material Technology : Sputtering of Compound Materials*.

Wasa, Kiyotaka & Hayakawa, Shigeru. (1992). *Handbook of Sputter Deposition Technology : Principles, Technology and Applications*. New Jersey : Noyes Publication.

Yunas, Jumril & Muliani, Lia. (2001). *Aplikasi Sistem Sputtering Untuk Deposisi Lapisan Tipis*. [Online] Tersedia :

Zulkifli, Wisnu W. (2005). *Fabrikasi Elemen Sensor Gas Co Berbasis Media Aktif TiN (Titanium Nitrida) Dengan Metode Sputtering DC*. [Online] Tersedia : [www.its.ac.id](http://www.its.ac.id).

